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Micro- and nanomachined tools for measuring thermopower and in-plane thermal conductivity of thermoelectric thin films AZURE AV-ERY, RUBINA SULTAN, GREG STIEHL, BARRY ZINK, University of Denver — Many of the potential next-generation thermoelectric materials being studied are either thin films or nanostructures that are expected to have anisotropic properties. Techniques such as the 3ω method and picosecond thermore flectance allow accurate measurements of k_{\perp} at temperatures relevant to thermoelectrics, but measuring k_{\parallel} is often difficult. In this talk we discuss our efforts to design and demonstrate accurate measurements of k_{\parallel} of thin films from 77 – 475 K using micro- and nanomachined thermal isolation platforms. Using thin-film structures to support the thin-film sample reduces background contributions, and careful control of the geometry keeps radiation errors small. We will discuss the optimization and micromachining of the measurement platforms and their application for studying the growth and characteristics of our first doped amorphous thin films. We will present our first tests of the devices on materials with established thermal properties. Finally, we will discuss the use of these measurement platforms to determine k and ZT for doped amorphous silicon thin films.

> Azure Avery University of Denver

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